



CTL0266NS-R3

N-Channel Enhancement MOSFET

Features

- Drain-Source Breakdown Voltage $V_{DS} - 20\text{ V}$
- Drain-Source On-Resistance
 $R_{DS(ON)} 82\text{m}\Omega$, at $V_{GS} = 10\text{V}$, $I_D = 2.6\text{A}$
 $R_{DS(ON)} 96\text{m}\Omega$, at $V_{GS} = 4.5\text{V}$, $I_D = 2.1\text{A}$
- Continuous Drain Current at $T_C = 25^\circ\text{C}$ $I_D = 2.6\text{A}$
- Advanced high cell density Trench Technology
- RoHS Compliance & Halogen Free

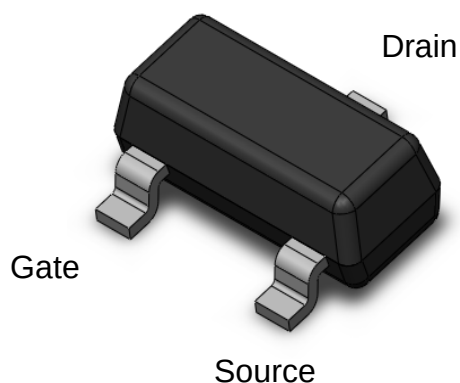
Applications

- Power Management
- Lithium Ion Battery

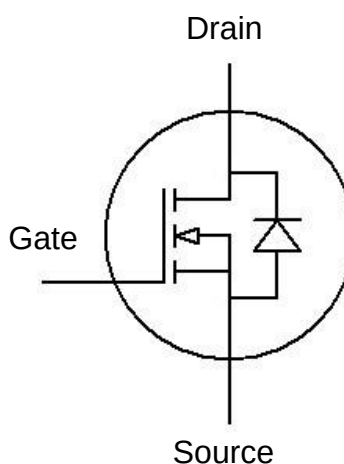
Description

The CTL0266NS-R3 is the N-Channel logic enhancement mode power field effect transistors are produced using high cell density, DMOS trench technology. This high density process is especially tailored to minimize on-state resistance. These devices are particularly suited for low voltage application such as cellular phone and notebook computer power management and other battery powered circuits where high-side switching and low in-line power loss are needed in a very small outline surface mount package.

Package Outline



Schematic





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Absolute Maximum Rating at 25°C

Symbol	Parameters	Test Conditions	Min	Notes
V _{DS}	Drain-Source Voltage	60	V	
V _{GS}	Gate-Source Voltage	±20	V	
I _D	Continuous Drain Current	2.6	A	1
I _{DM}	Pulsed Drain Current	10	A	1
P _D	Total Power Dissipation	1.04	W	2
T _{STG}	Storage Temperature Range	-55 to 150	°C	
T _J	Operating Junction Temperature Range	-55 to 150	°C	

Thermal Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
R _{ΘJA4}	Thermal Resistance Junction-Ambient (t=10s)		--	110	--	°C /W	1,4

**CTL0266NS-R3****N-Channel Enhancement MOSFET****Electrical Characteristics** $T_A = 25^\circ\text{C}$ (unless otherwise specified)**Static Characteristics**

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
B _{VDS}	Drain-Source Breakdown Voltage	V _{GS} = 0V, I _D = -250μA	60	-	-	V	
I _{DSS}	Drain-Source Leakage Current	V _{DS} = 60V, V _{GS} = 0V	-	-	-1	μA	
I _{GSS}	Gate-Source Leakage Current	V _{GS} = ±20V, V _{DS} = 0V	-	-	±100	nA	

On Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
R _{DS(ON)}	Drain-Source On-Resistance	V _{GS} = 10V, I _D = 2.6A	-	82	100	mΩ	3
		V _{GS} = 4.5V, I _D = 2.1A	-	96	130	mΩ	
V _{GS(th)}	Gate-Source Threshold Voltage	V _{GS} = V _{DS} , I _D = -250μA	1.0	---	3.0	V	3

Dynamic Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
C _{ISS}	Input Capacitance	V _{GS} = 0V, V _{DS} = 30V f = 1MHz	-	350	-	pF	
C _{OSS}	Output Capacitance		-	40	-		
C _{RSS}	Reverse Transfer Capacitance		-	12	-		

Switching Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
T _{D(ON)}	Turn-On Delay Time	V _{DS} = 20V , V _{GS} = 10V, R _G = 1Ω, R _L = 20Ω,	-	10	-	ns	
T _R	Rise Time		-	11	-		
T _{D(OFF)}	Turn-Off Delay Time		-	29	-		
T _F	Fall Time		-	3	-		
Q _G	Total Gate Charge	V _{DS} = 30V , V _{GS} = 4.5V, I _D = 2.6A	-	6.5	-	nC	
Q _{GS}	Gate-Source Charge		-	2.2	-		
Q _{GD}	Gate-Drain Charge		-	2.7	-		



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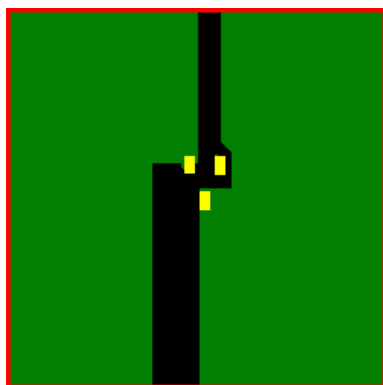
N-Channel Enhancement MOSFET

Drain-Source Diode Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
V_{SD}	Body Diode Forward Voltage	$V_{GS} = 0V, I_D = 1A$	-	0.8	1.2	V	
I_{SD}	Body Diode Continuous Current		-	-	2.1	A	1

Note:

1. The power dissipation is limited by 150°C junction temperature.
2. Device mounted on a glass-epoxy board



FR-4
25.4 × 25.4 mm .
2 Oz Copper

Test Board

3. The data tested by pulsed , pulse width $\leq 300\mu s$, duty cycle $\leq 2\%$
4. Thermal Resistance follow JESD51-3.



Typical Characteristic Curves

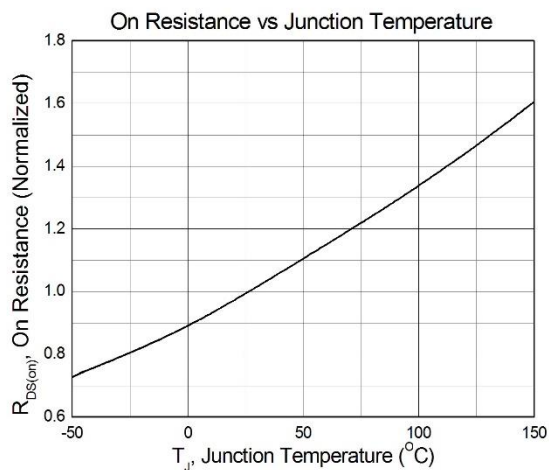


Figure 1

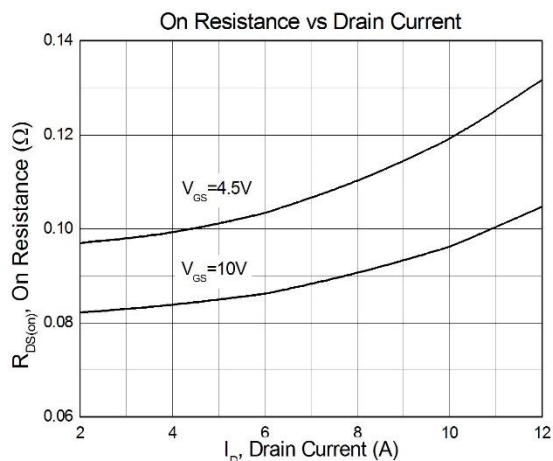


Figure 2

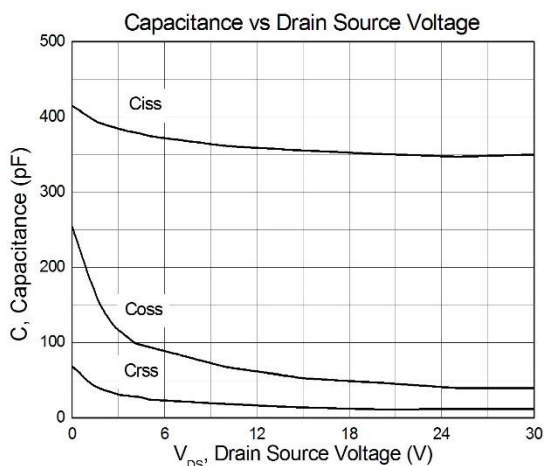


Figure 3

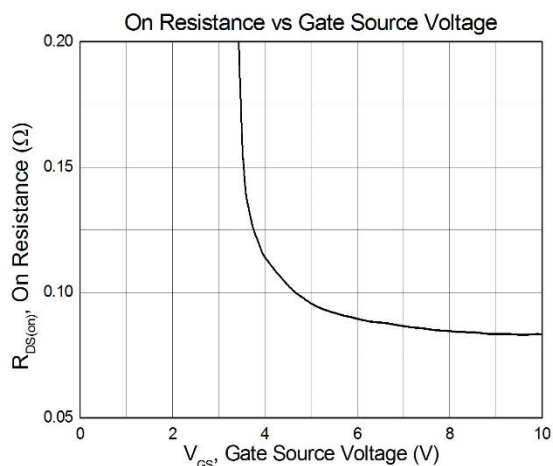


Figure 4

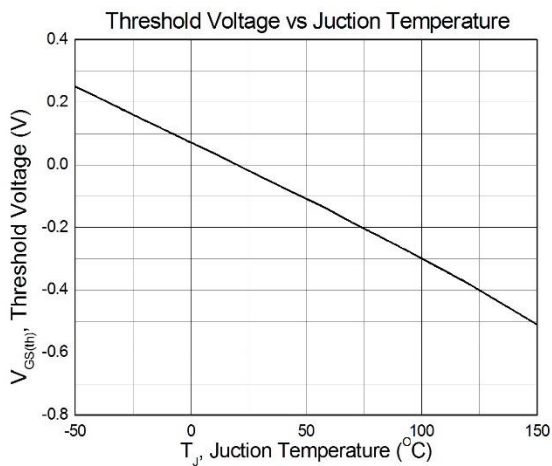


Figure 5

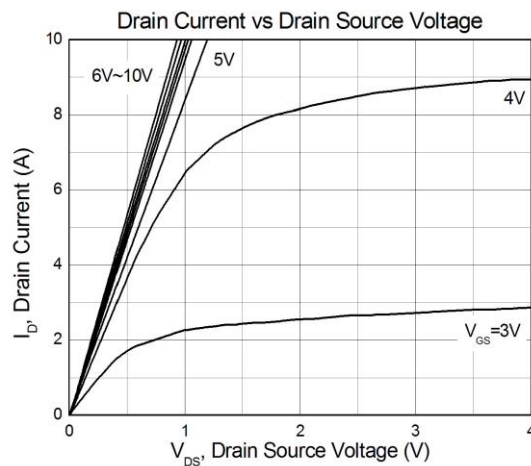
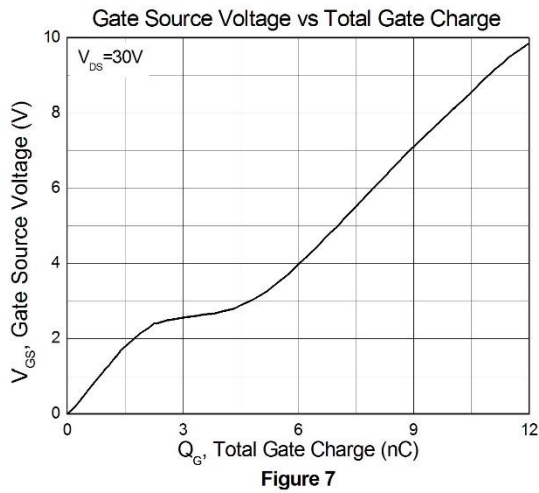
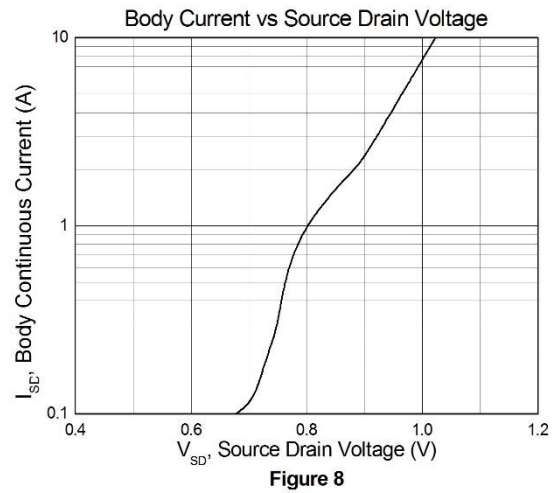


Figure 6



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Test Circuits & Waveforms

Figure 12: Gate Charge Test Circuit

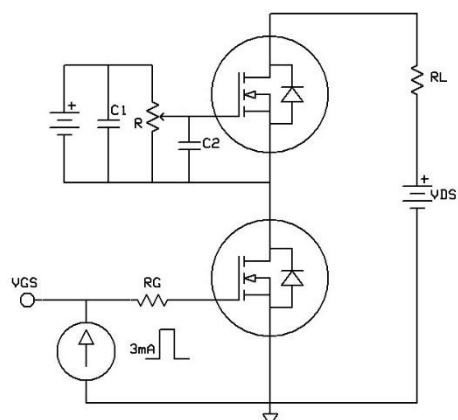


Figure 14: Switching Time Test Circuit

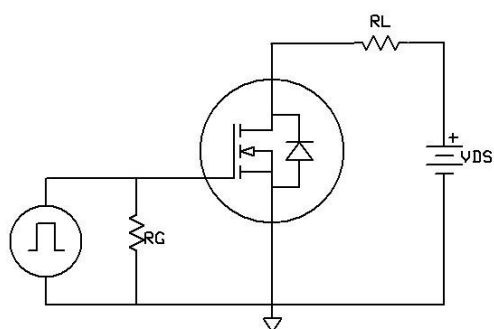


Figure 13: Gate Charge Waveform

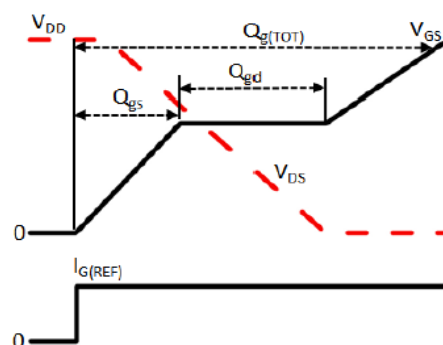
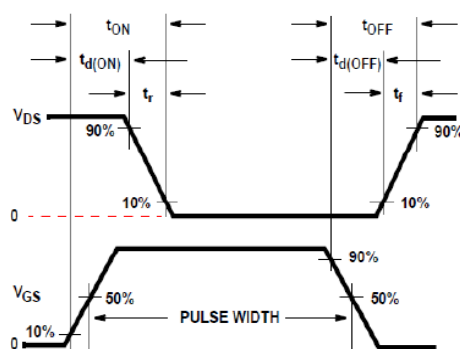
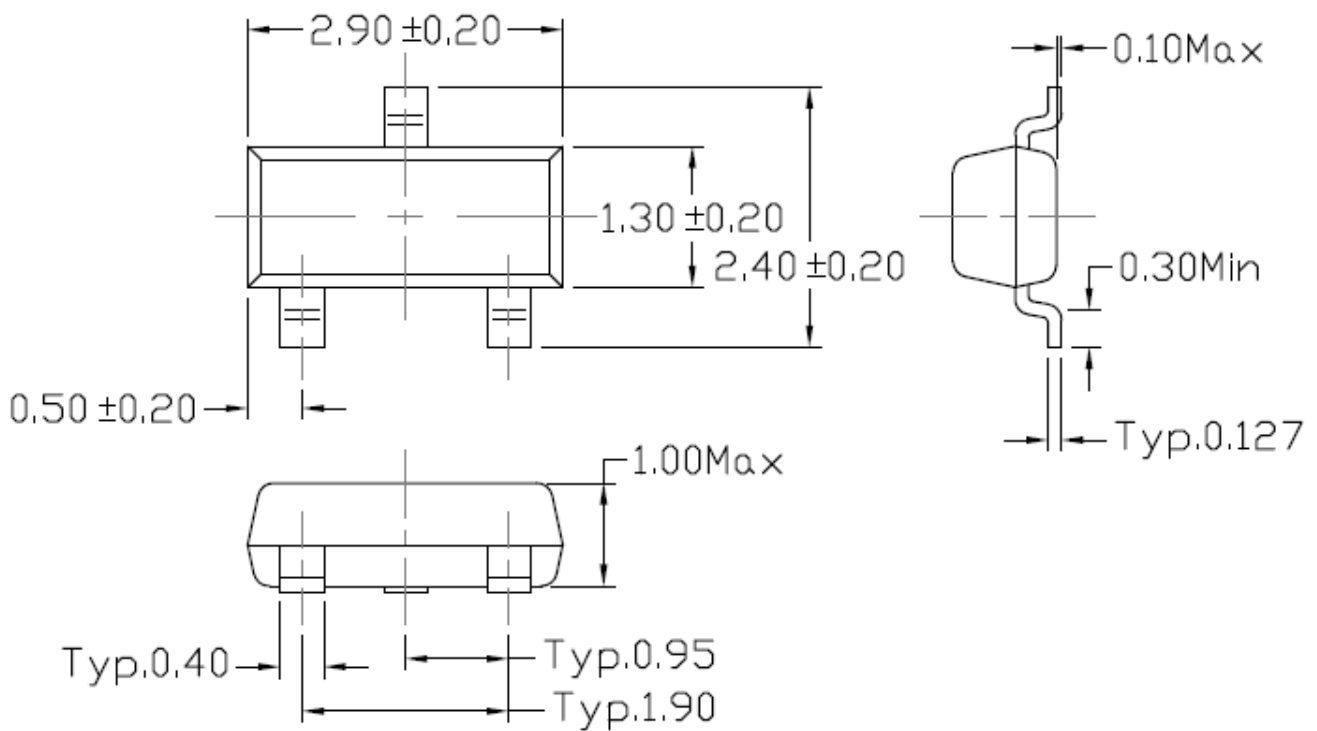


Figure 15: Switching Time Waveform

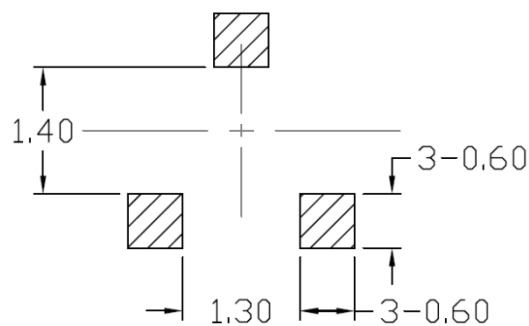




Package Dimension (SOT-23)



Recommended pad layout for surface mount leadform

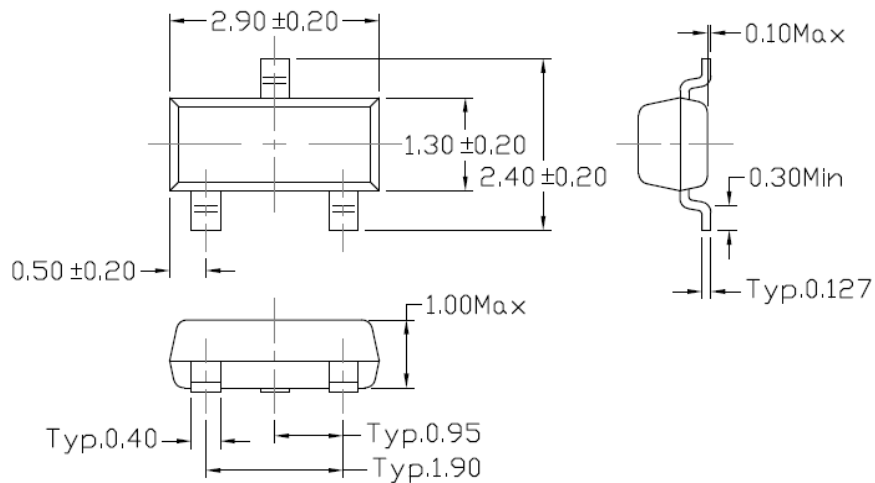




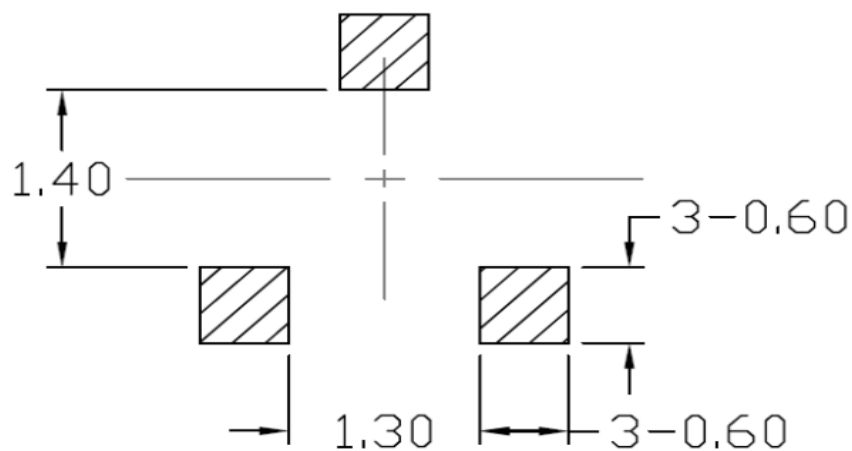
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Package Dimension *Dimensions in mm unless otherwise stated*



Recommended pad layout for surface mount leadform

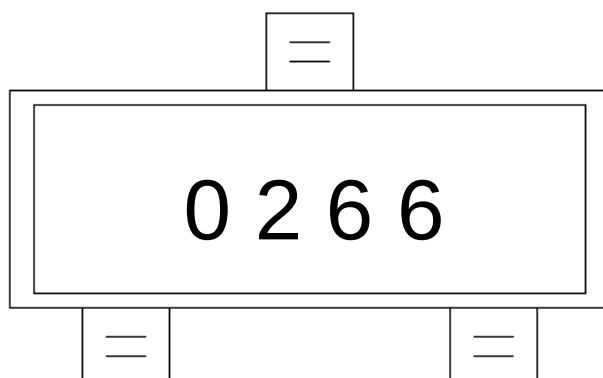




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Marking Information



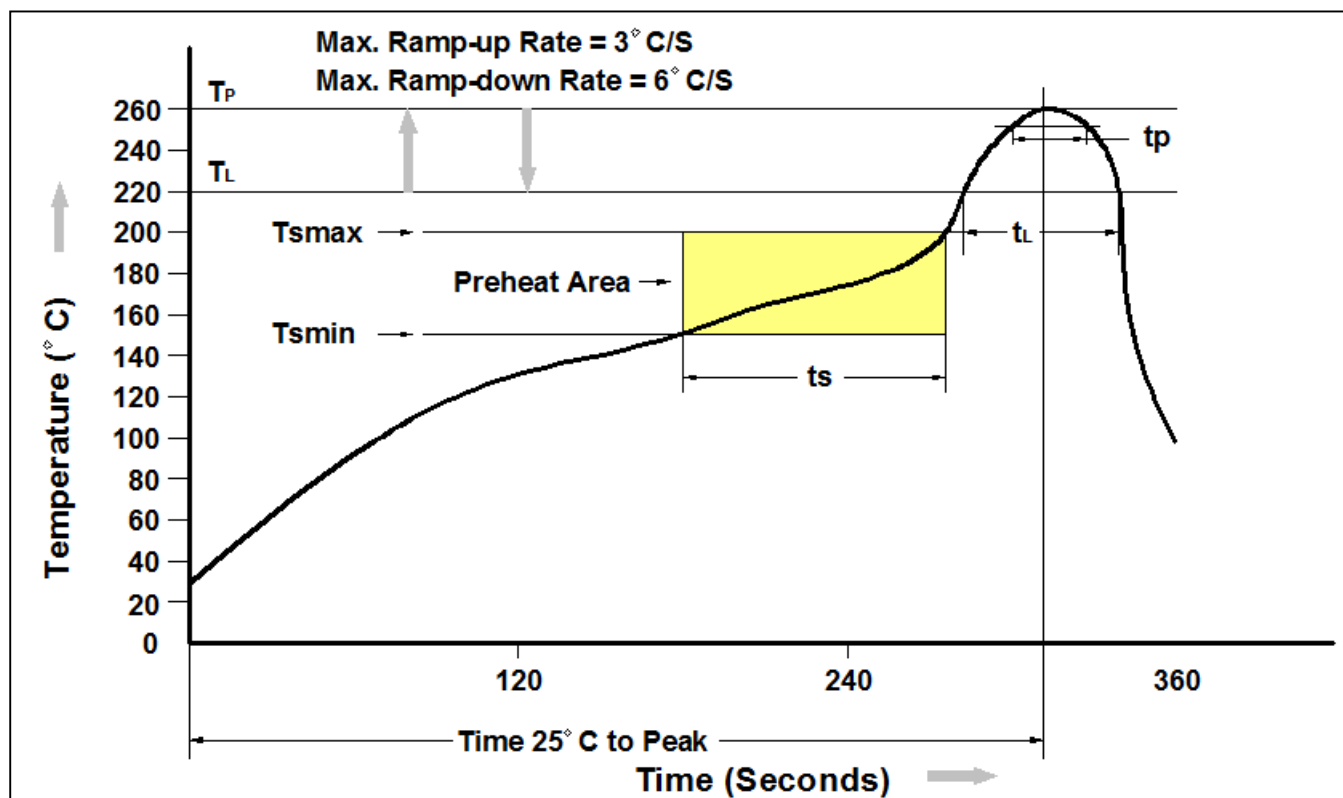
0266: Device Number

Ordering Information

Part Number	Description	Quantity
CTL0266NS-R3	SOT-23 Reel	3000 pcs



Reflow Profile



Profile Feature	Pb-Free Assembly Profile
Temperature Min. (T _{smin})	150°C
Temperature Max. (T _{smax})	200°C
Time (t _s) from (T _{smin} to T _{smax})	60-120 seconds
Ramp-up Rate (t _L to t _P)	3°C/second max.
Liquidous Temperature (T _L)	217°C
Time (t _L) Maintained Above (T _L)	60 – 150 seconds
Peak Body Package Temperature	260°C +0°C / -5°C
Time (t _P) within 5°C of 260°C	30 seconds
Ramp-down Rate (T _P to T _L)	6°C/second max
Time 25°C to Peak Temperature	8 minutes max.



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